

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:)
)
Osamu Nozawa et al.)
)
Serial No.: 10/771,997)
)
Filed: February 4, 2004)
)
For: Manufacturing Method And Apparatus of)
Phase Mask Shift Blank)
)
Examiner: Rodney Glenn McDonald)
)
Confirmation No.: 4072)
)
Art Unit: 1753)

AMENDMENT G (AFTER FINAL)

Commissioner of Patents
P. O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Applicants have the following response to the Final Rejection of April 26, 2007, a RCE and a three month extension of time being submitted herewith.

Please amend the above-identified application as follows: